

From Pollutant to Non-Toxic Product: Ov-Rich S-scheme Heterojunction for Photocatalytic Antibiotic Degradation and Toxicity Assessment

Gulgina Mamtmin^{a,*}, Zehua Yuan^a, Munire Tuerhong^{#,a}, Jinhua Liang^b, Xirenayi Aisikaer^c, Jubao Zhang^d

Xinjiang Key Laboratory of Novel Functional Materials Chemistry, College of Chemistry and Environmental Sciences, Kashi University, Kashi 844000, PR China

*Corresponding authors. Email: gulgina125@sina.com

3. Results and discussion

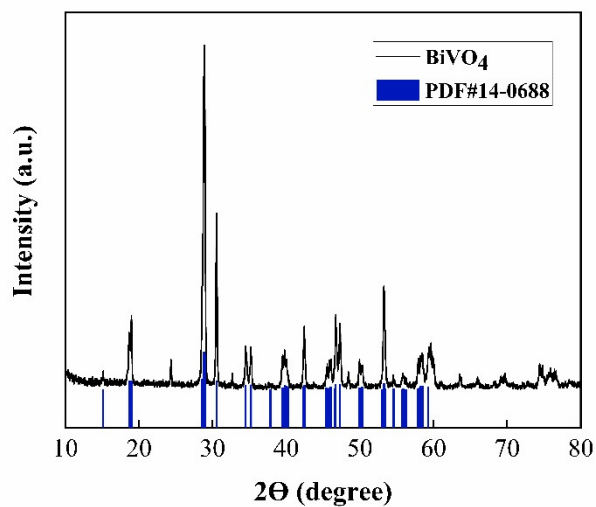


Fig. S1. The XRD pattern of BiVO₄

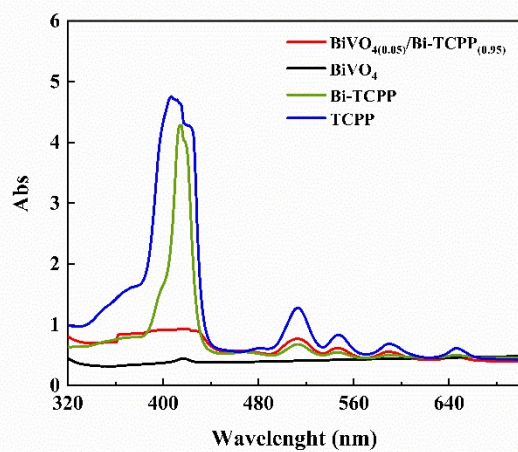
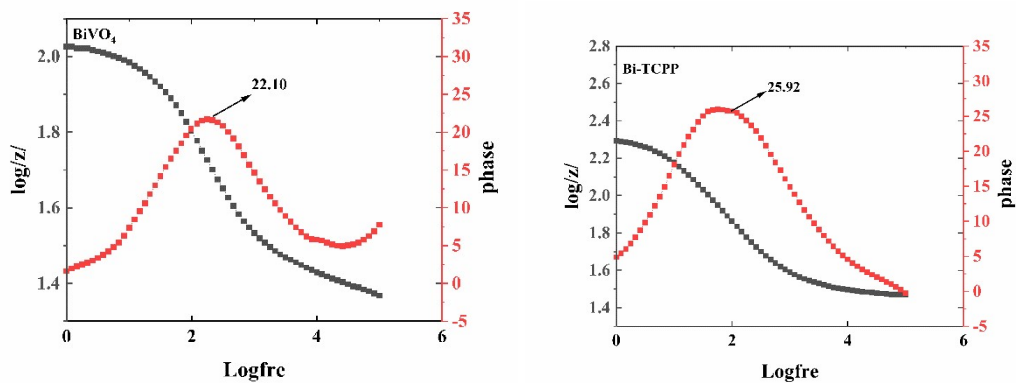


Fig. S2. UV-Vis spectra of TCPP, Bi-TCPP, BiVO₄ and 5%BiVO₄/Bi-TCPP



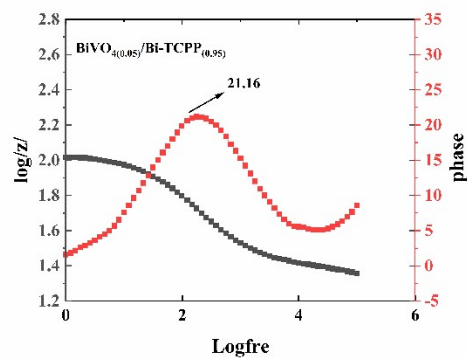


Fig. S3. EIS Bode plots of BiVO₄, Bi-TCPP and 5%BiVO₄/Bi-TCPP

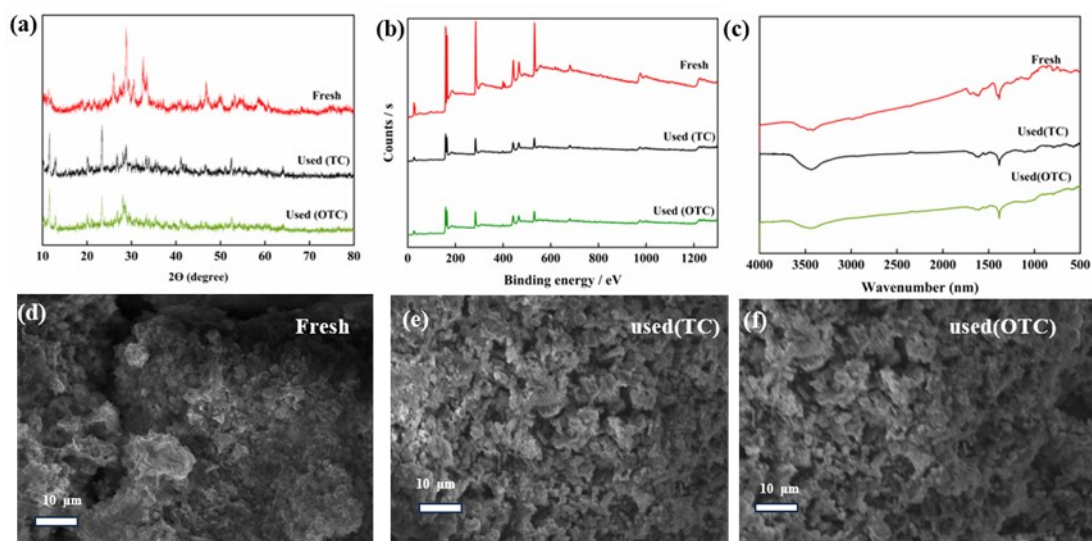
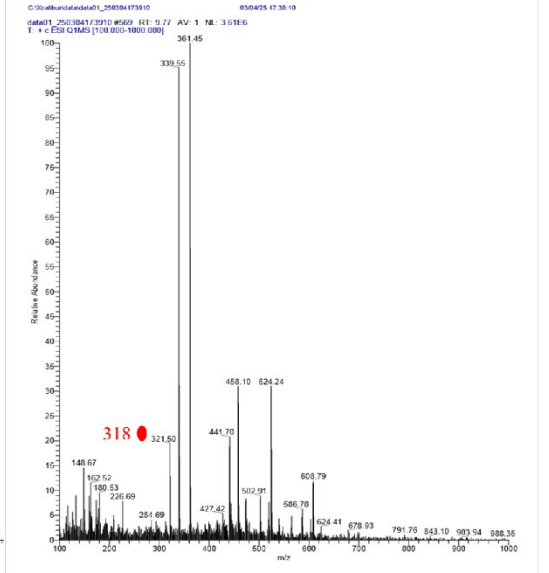
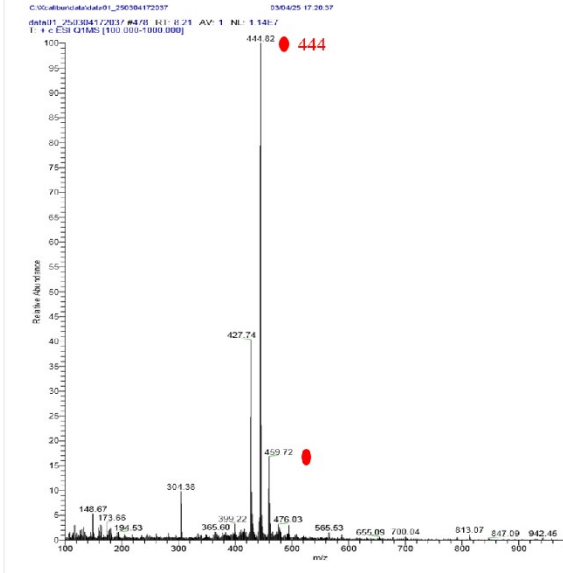
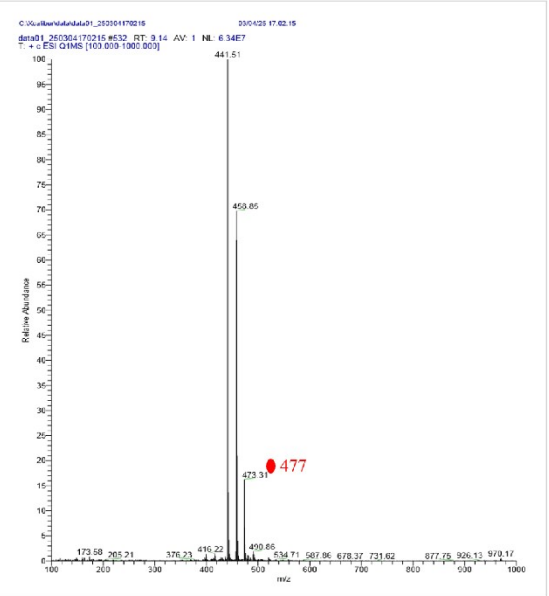
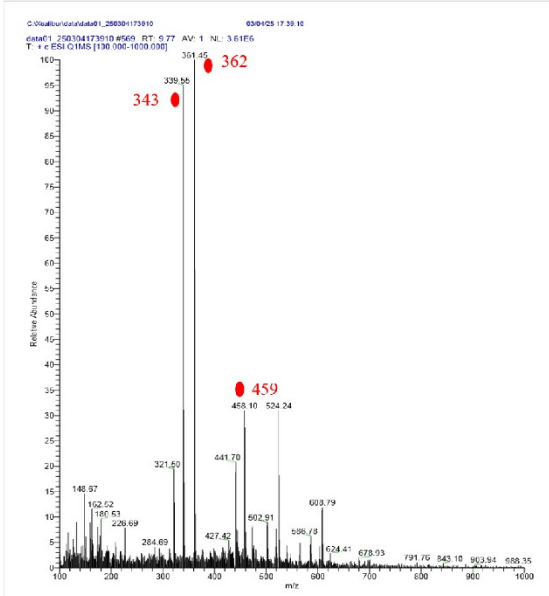


Fig. S4. Characterization of the photocatalyst before and after use: (a) XRD patterns, (b) XPS survey spectra, (c) FTIR spectra, and (d-f) SEM images of fresh and used catalysts.



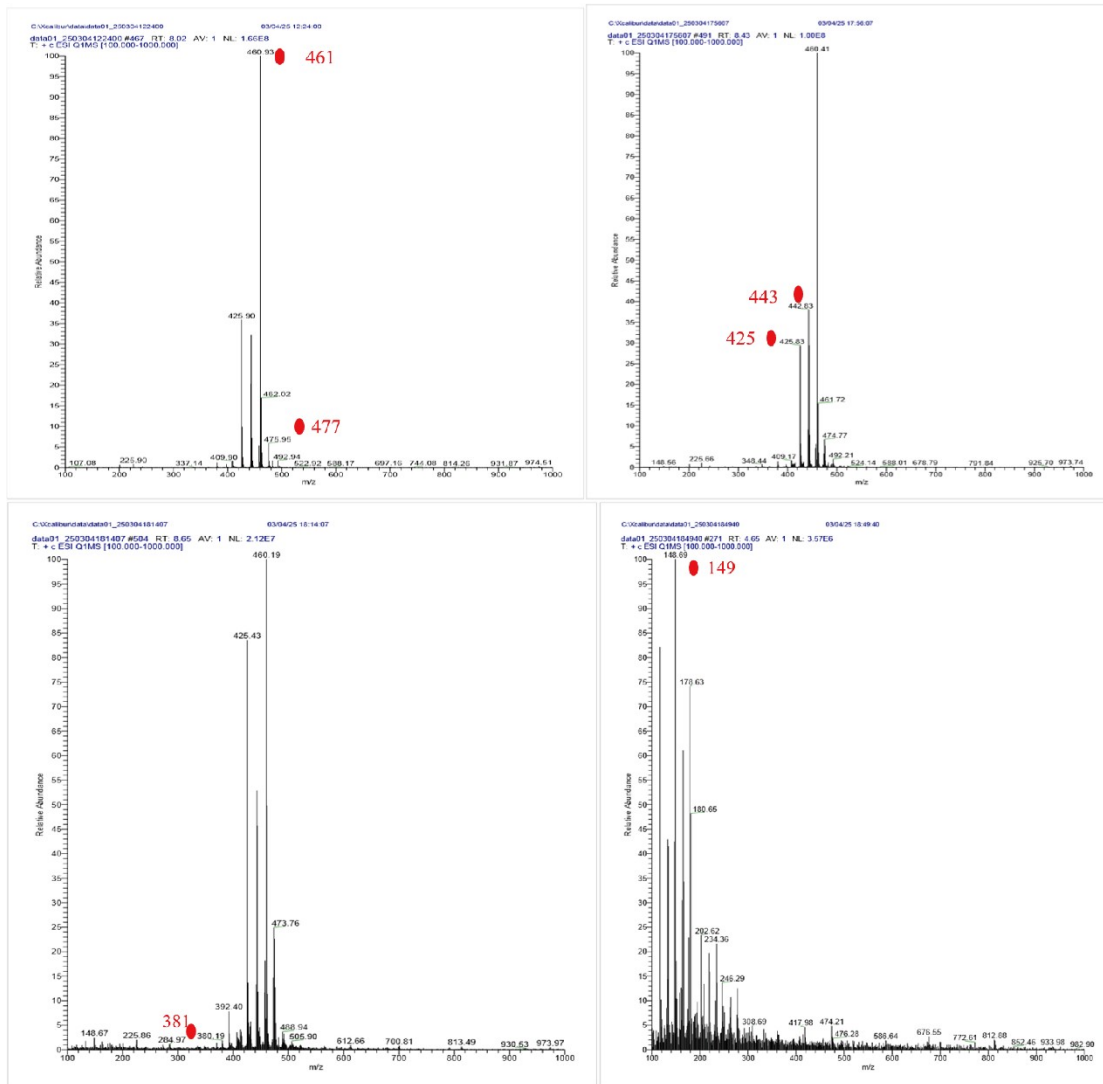


Fig. S5. MS/MS results of the reaction between TC and OTC with BiVO₄/Bi-TCPP.

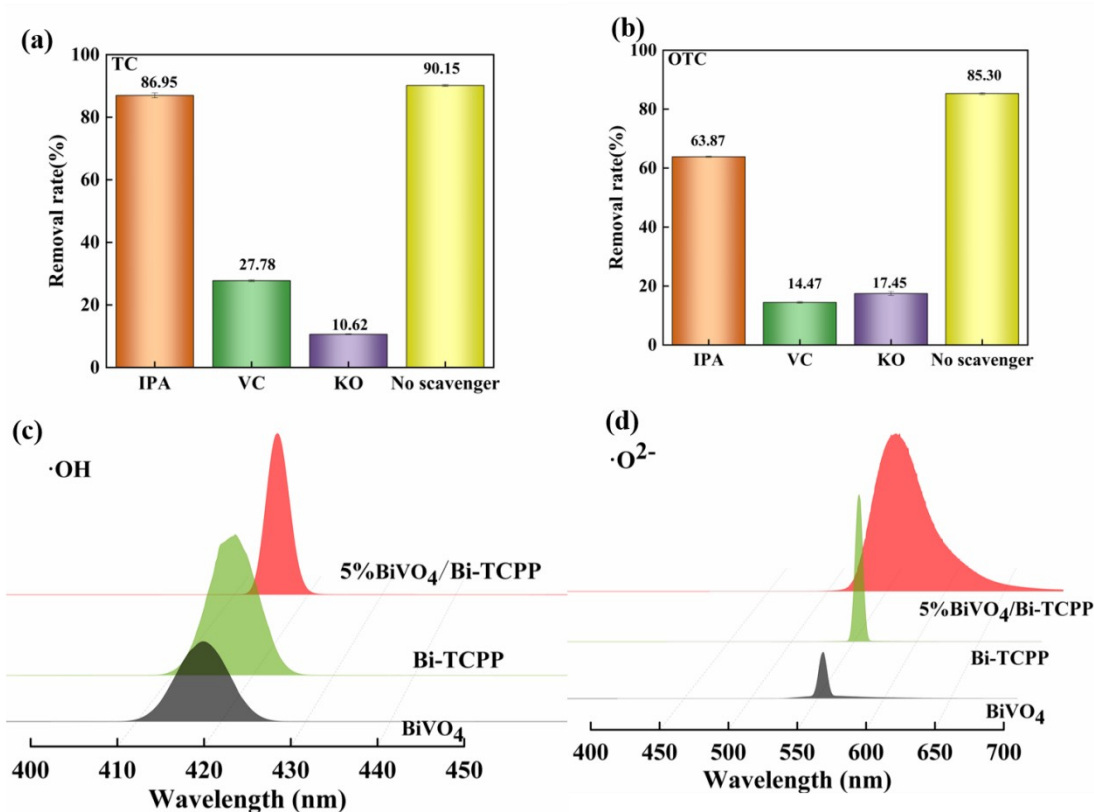


Fig. S6. Effects of diverse scavengers on the photo-oxidation of TC (a) and OTC (b). Relationship curve between the absorbance and the concentration of 2-OH-TA (c) and FS (d) in different systems.

Tables

Table S1 The specific surface areas, average pore size and pore volume of samples.

samples	BET (m^2/g)	Average pore diameter (nm)	Pore volume (cm^3/g)
BiVO_4	2.58	3.88	0.0050
Bi-TCPP	11.87	18.33	0.0389
$\text{BiVO}_4/\text{Bi-TCPP}$	20.45	3.81	0.0544

Table S2 Comparison of photocatalytic degradation performance of representative photocatalysts for tetracycline antibiotics.

Photocatalyst	Target Pollutant	Removal Efficiency	Reaction Time	Ref
BiVO ₄ /Bi-TCPP	TC	90.15%	90 min	This work
BiVO ₄ /Bi-TCPP	OTC	85.30%	120 min	This work
Cu ₂ O/BiVO ₄	TC	78.90%	24 min	1
ZnO/BiVO ₄	OTC	88%	240 min	2
AgI/BiVO ₄	TC	94.91%	60 min	3
PCN-224 (Zr-TCPP MOF)	TC	92%	180 min	4

1. L. R. Xing, Z. J. Zhang, Y. H. Zhang and L. Ji, *Catalysts*, 2026, **16**, 63.
2. K. Wannakan, K. Khansamrit, T. Senasu and S. Nanan, *ACS Omega*, 2023, **5**, 4835-4852.
3. F. Chen, Q. Yang, J. Sun, F. B. Yao, S. Wang, Y. L. Wang, X. L. Wang, X. M. Li, C. G. Niu, D. B. Wang and G. M. Zeng, *ACS Appl. Mater. Interfaces*, 2016, **8**, 32887-32900.
4. Y. Q. Zong, S. S. Ma, J. M. Gao, M. J. Xu, J. J. Xue and M. X. Wang, *ACS Omega*, 2021, **6**, 17228-17238.